



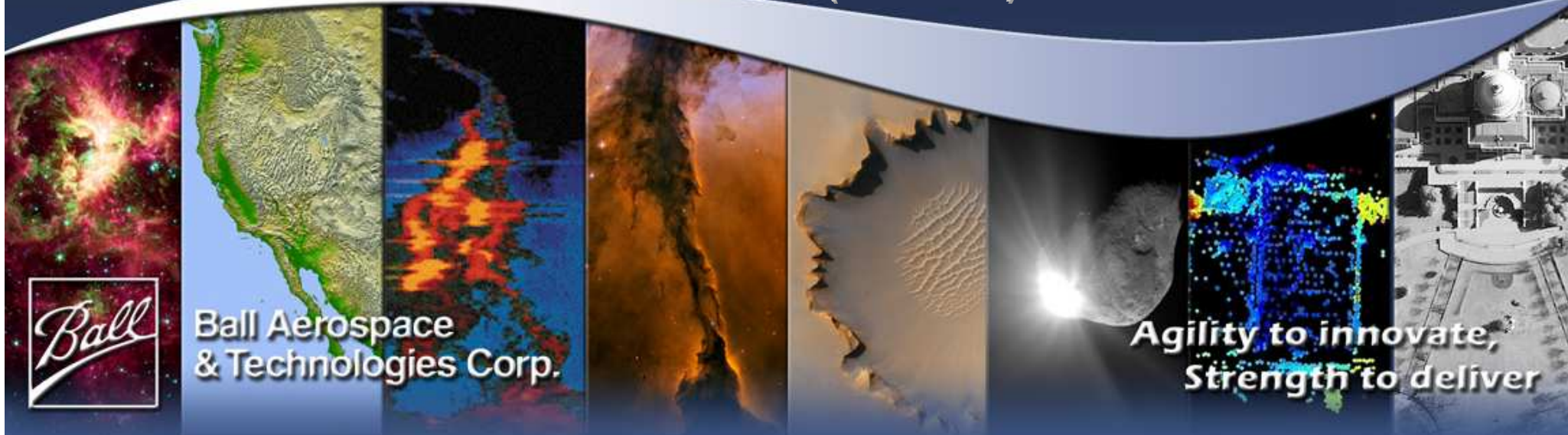
NLSI CCLDAS

Surfaces that Shed Dust:

Development, Performance and Characterization

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(CCLDAS)



Ball Aerospace
& Technologies Corp.

Agility to innovate,
Strength to deliver



Who we are: Ball Aerospace and Technologies



LATEST NEWS: Ball/Boeing Team Completes Segment Testing of Space Surveillance Satellite System

Ball Aerospace sponsors PBS documentary, "400 Years of the Telescope." [Read more...](#)

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Space-based Instruments and Sensors



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PROGRAMS

Program Profile:
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CCLDAS

The Colorado Center
for Lunar Dust and
Atmospheric Studies



About CCLDAS

We study the lunar dust/plasma environment through a combination of modeling, theoretical work and laboratory experiments.

We develop new experimental processes to determine:

- The effects that a charged surface mobilizing dusty particles affects the lunar atmosphere
- How solar radiation is responsible for the lunar dusty atmosphere
- How dust can be mitigated on lunar missions

We provide experimental facilities to scientists and institutions around the world with the following capabilities:

- *Dust accelerators:* 3 MeV and 'mini' 20 kV
- *Large and small test chambers:* includes lunar environment simulators
- *Main Lab:* ~5000 ft²
- *Office/Conference Space:* ~5000 ft²
- *Lab founded:* 2009



D.R. Scott (Apollo 15). The apparent "haze" above the hills is caused by dust on the camera lens. (Courtesy of NASA)



Motivation: Limiting terrestrial particulate contamination



Engineers at Ball Aerospace examining Be mirror for the James Webb Space Telescope for particulate (dust, lint) and molecular contamination.



Motivation: Limiting moon dust contamination



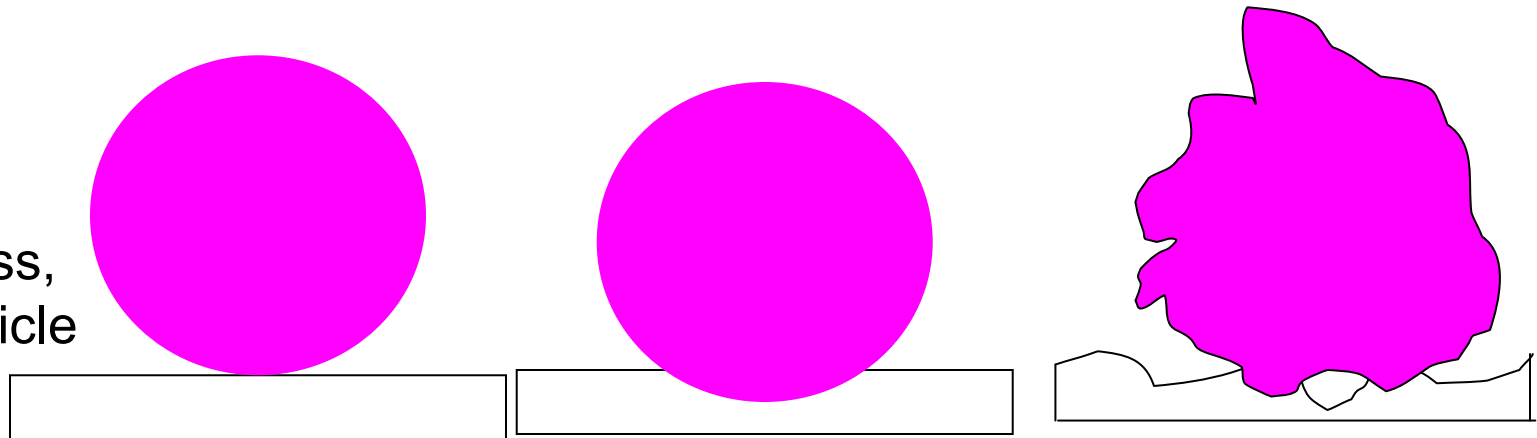
Apollo 17 commander Eugene Cernan after a day of moonwalking.



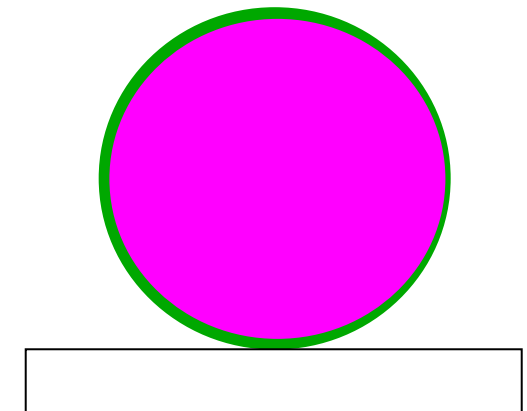
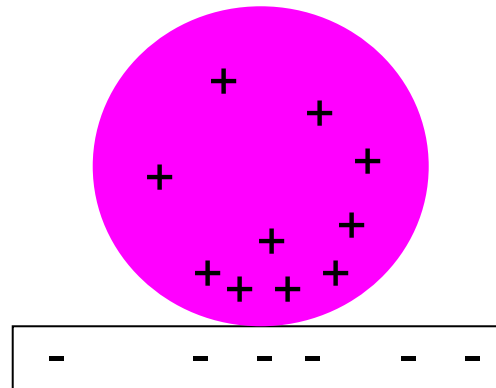
- **THE BIG GOAL: ENGINEER SURFACES SUCH THAT DUST IS NOT ATTRACTED TO THE TARGET SURFACE AND IF IT ENDS UP THERE, CAN EASILY BE REMOVED.**

- **THE SUB-GOAL: TO EXPLORE AND UNDERSTAND UNDERLYING MECHANISMS AS A PATHWAY TO THE BIG GOAL.**
 - EMPIRICAL WORK
 - CHARACTERIZATION

Contact area:
Effect of hardness,
surface and particle
morphology



Coulomb force,
charge transfer,
Van der Waals
(induced dipole
Interaction)

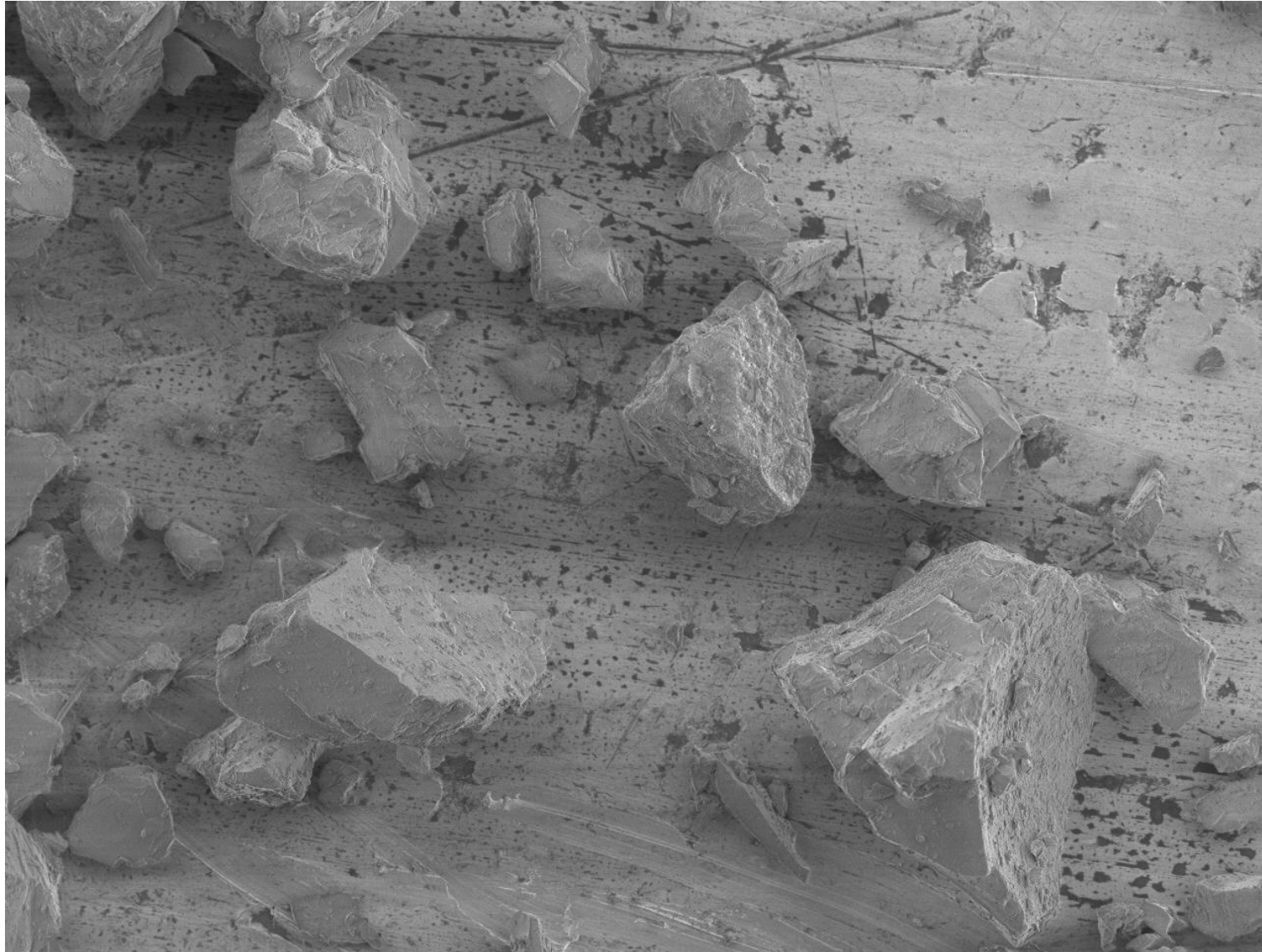


Surface films: oxidation,
humidity, chemical reactions

Others: magnetic effects, sintering, interfacial mixing, alloying, etc....



Our Dust: JSC-1AF Simulant



Ball ATC

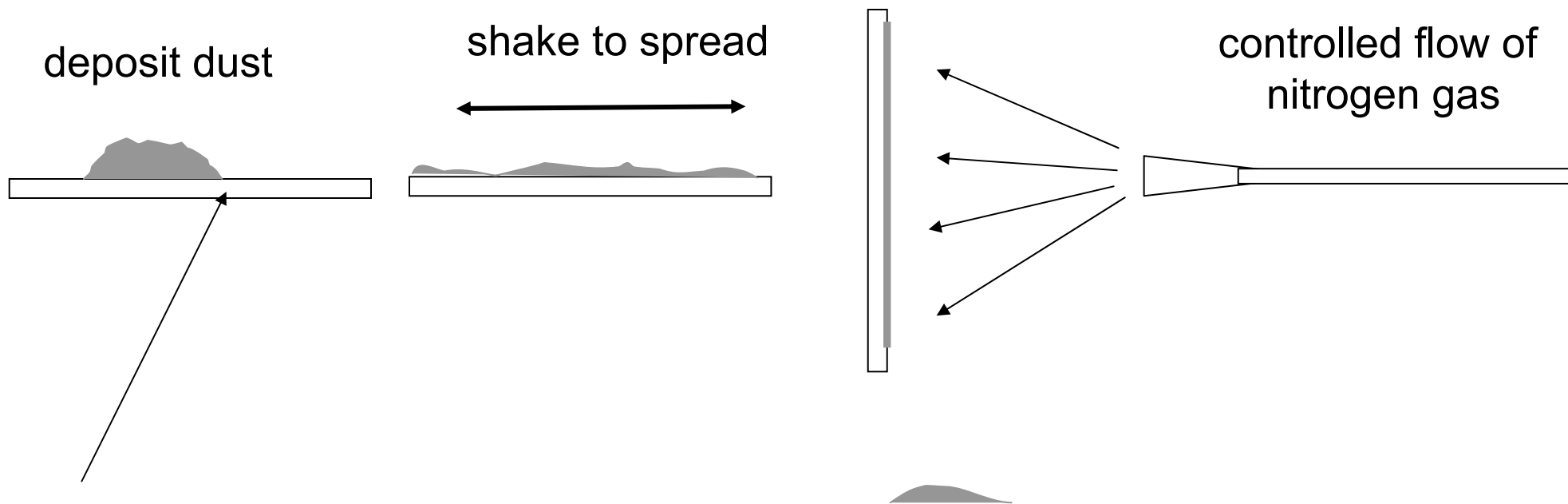
SEI

1.0kV

X850

WD 8.9mm

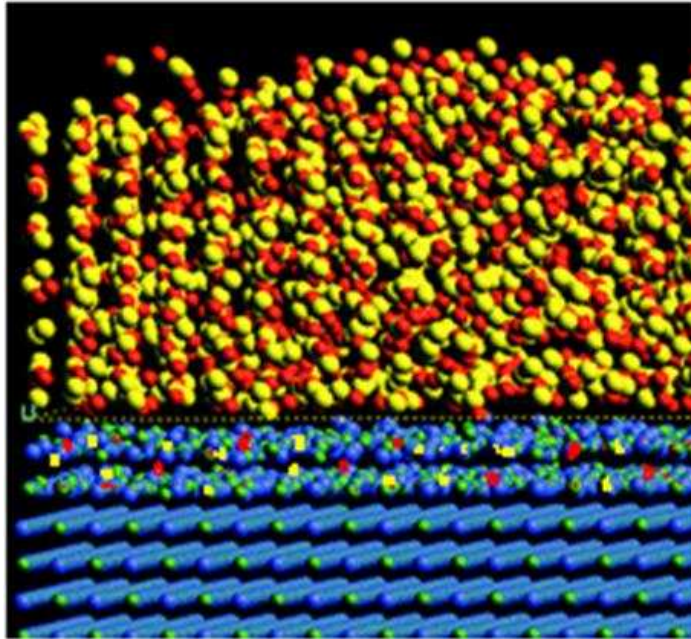
10 μ m



Substrates: black Kapton, silicon, polycarbonate, quartz (~1 sq. in)

with various

Surface Types: Virgin, Teflon-like coating, BATC proprietary treatment

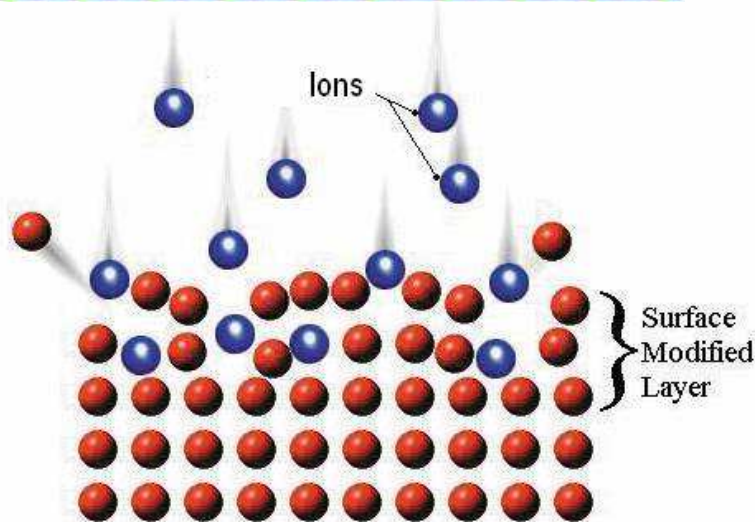


Film Deposition:

Material added to a substrate.

Thicknesses vary from monolayer coverage to relatively thick films.

Interfacial layer depends upon the conditions of the deposition and type of substrate.



Surface Modification:

No net increase in thickness.

Surface composition modified. Balance between surface etching and deposition.



Black Kapton partially coated with C:F film



Black Kapton w/o Coating

Protective Coating

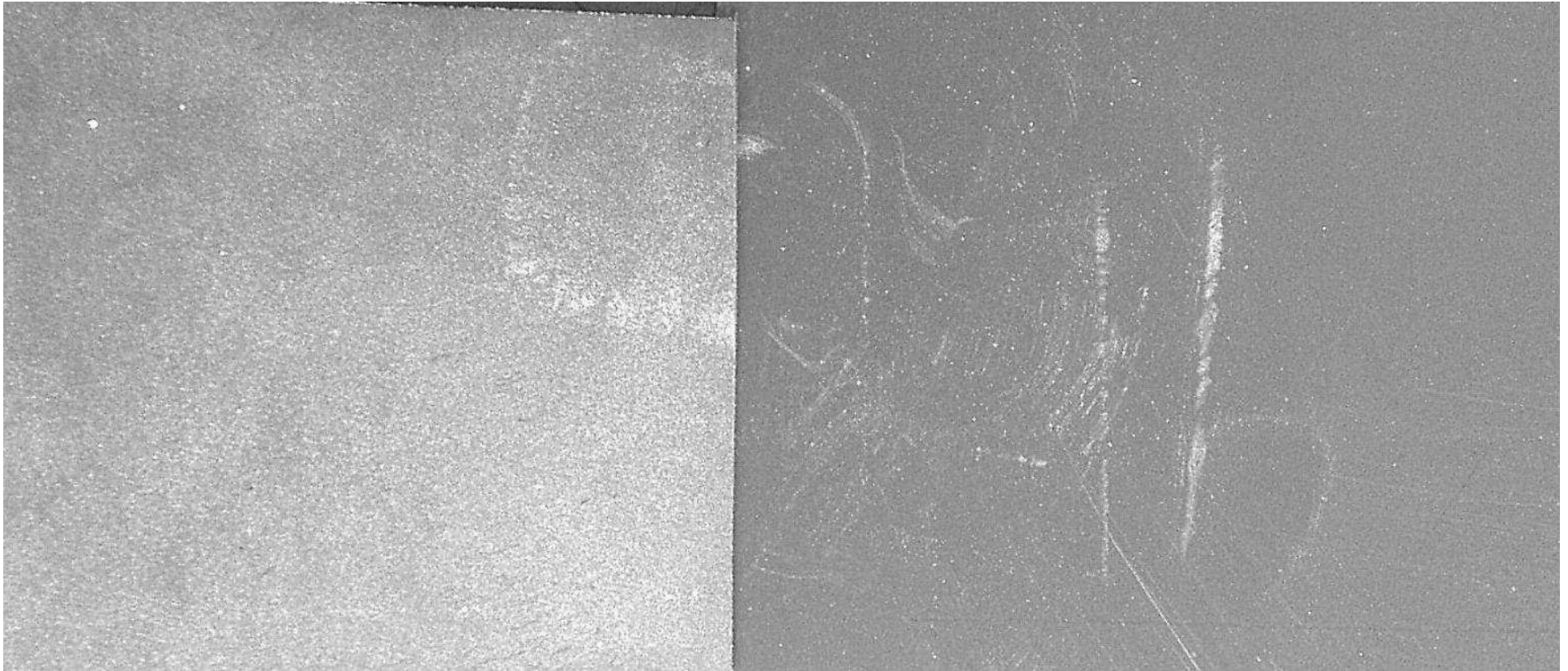


JSC-1AF (5 -45um) Lunar Simulant applied to full Kapton Sample

When tapped, the Lunar simulant readily falls from the Coated side of the Sample, while adhered to the uncoated side of the Kapton sample.



Black Kapton: Virgin and Treated



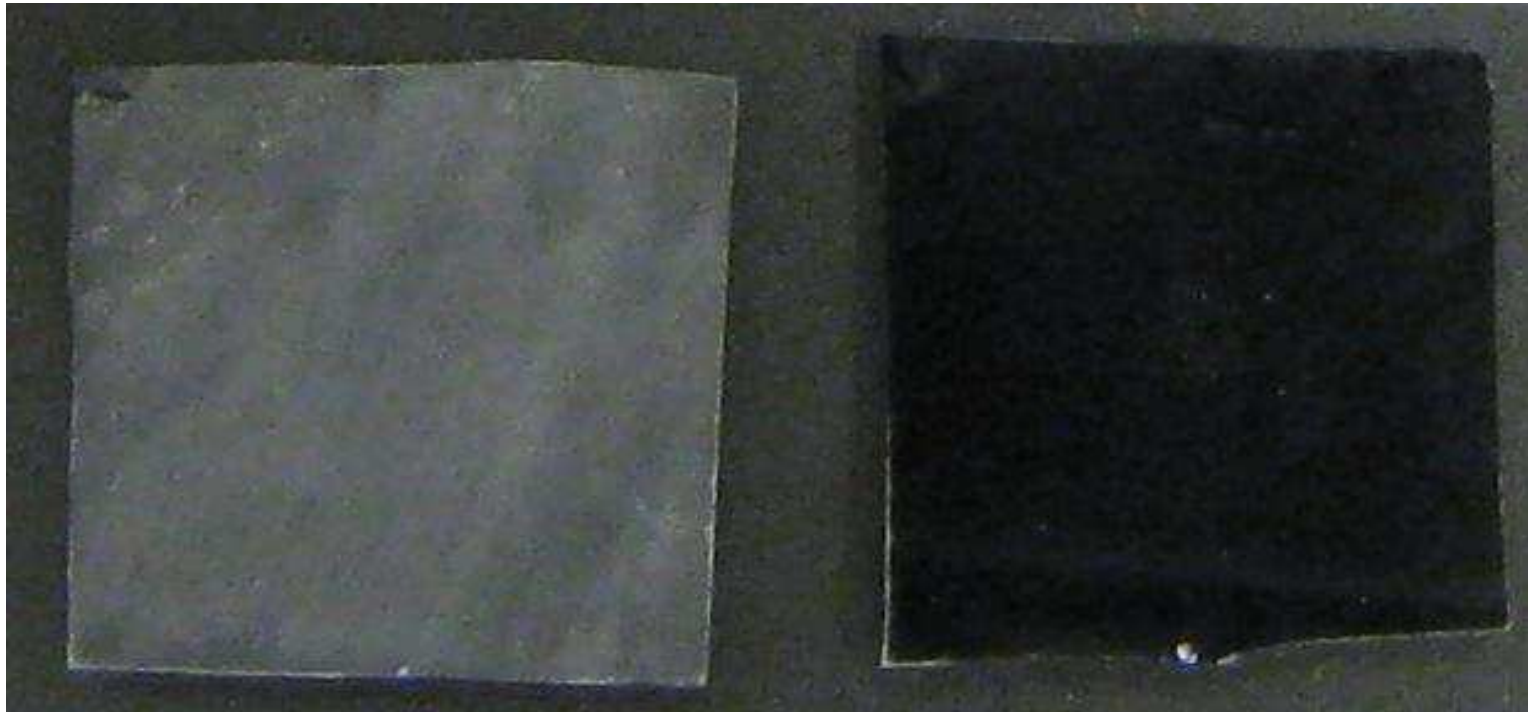
Virgin/dusted

Treated/dusted

BATC proprietary surface treatment



Silicon wafer: Virgin/dusted and treated/dusted



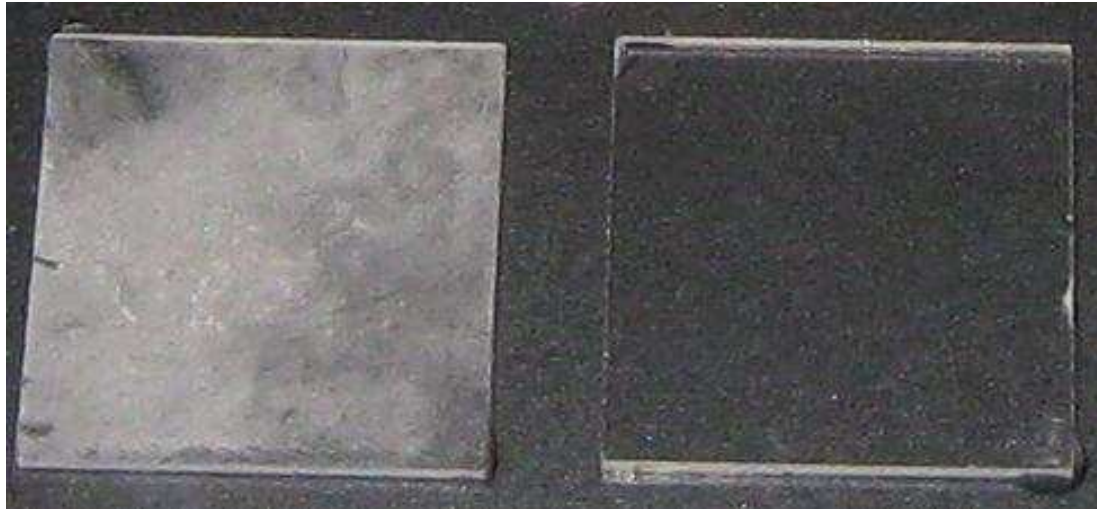
Virgin Si after dusting

Treated Si after dusting

BATC proprietary surface treatment



Quartz: Virgin/dusted and treated/dusted



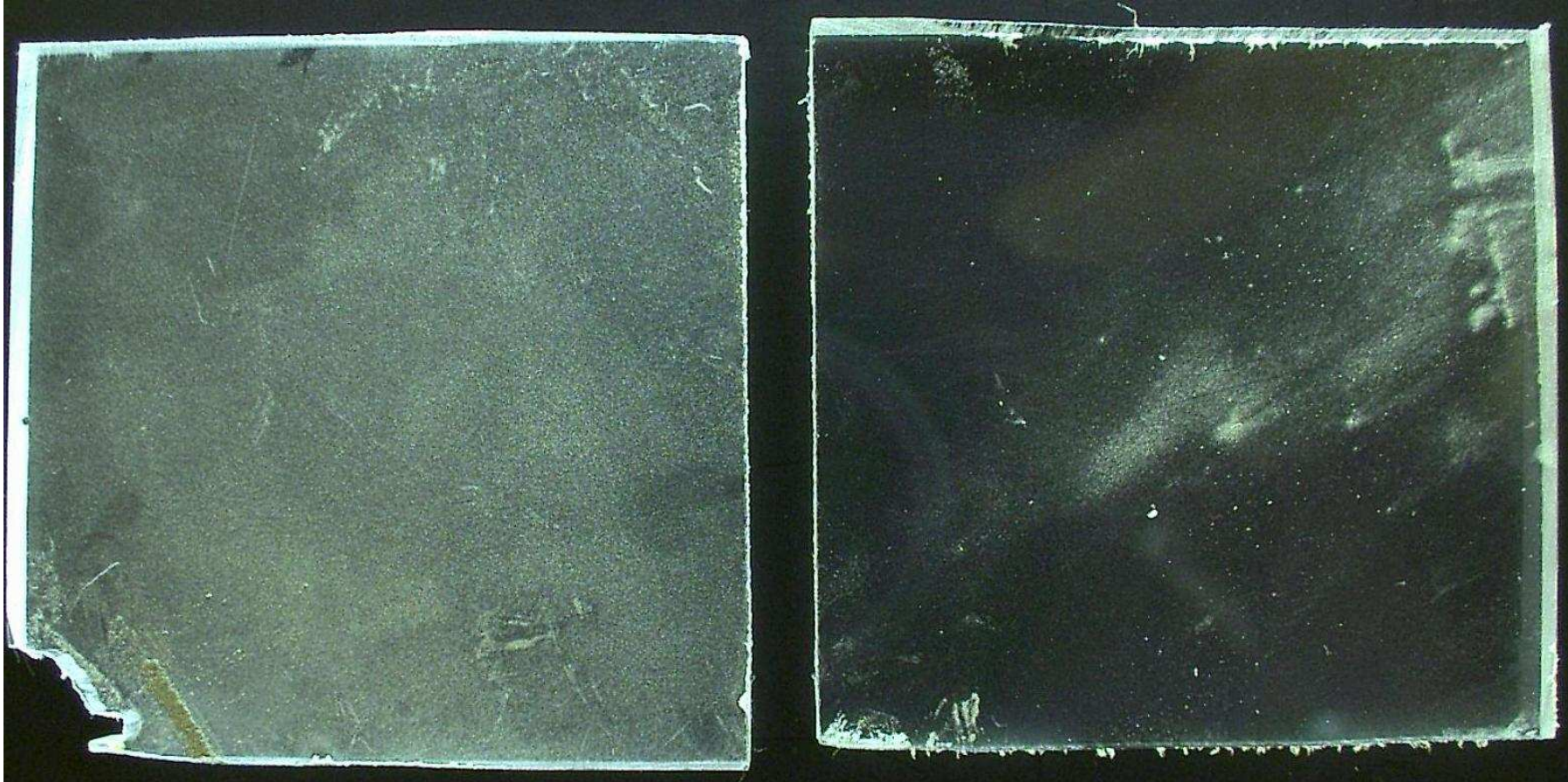
Virgin quartz after dusting

Treated quartz after dusting

BATC proprietary surface treatment



Results: Polycarbonate



Virgin polycarbonate after dusting

Treated polycarbonate after dusting

BATC proprietary surface treatment



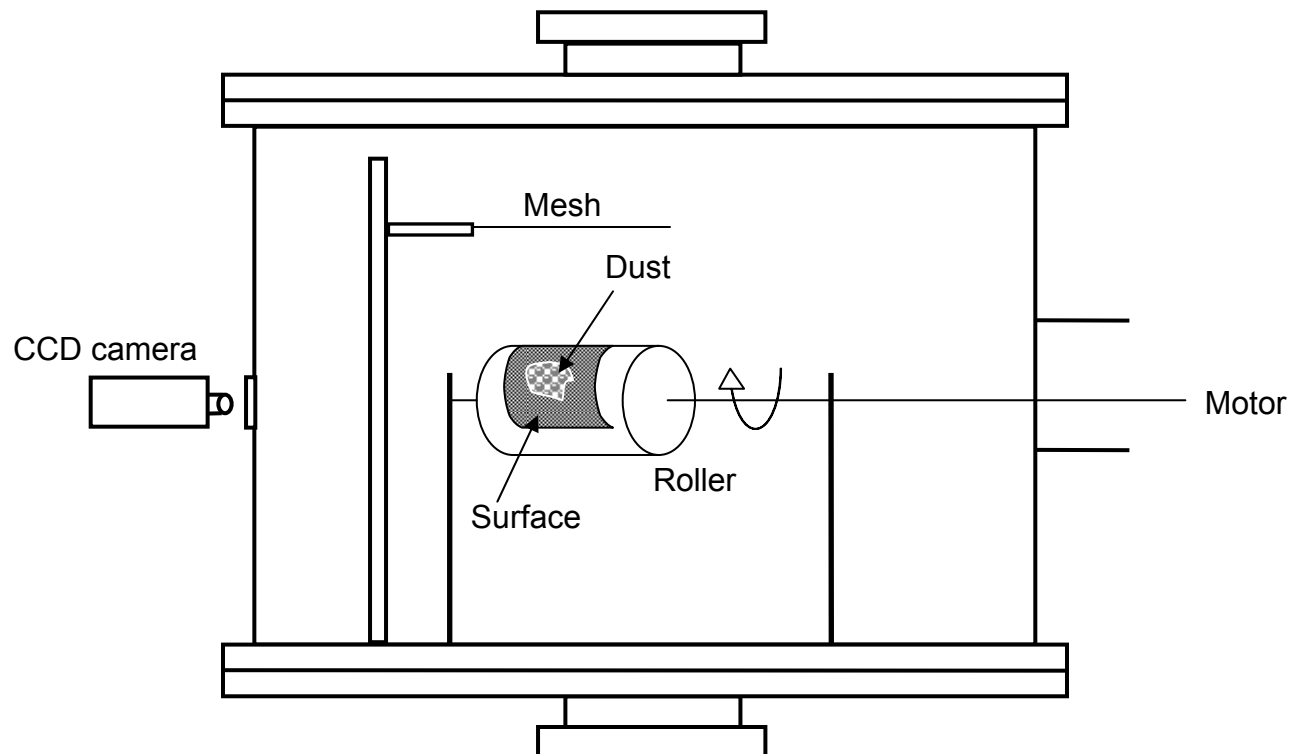
Summary of adhesion results:



In air:

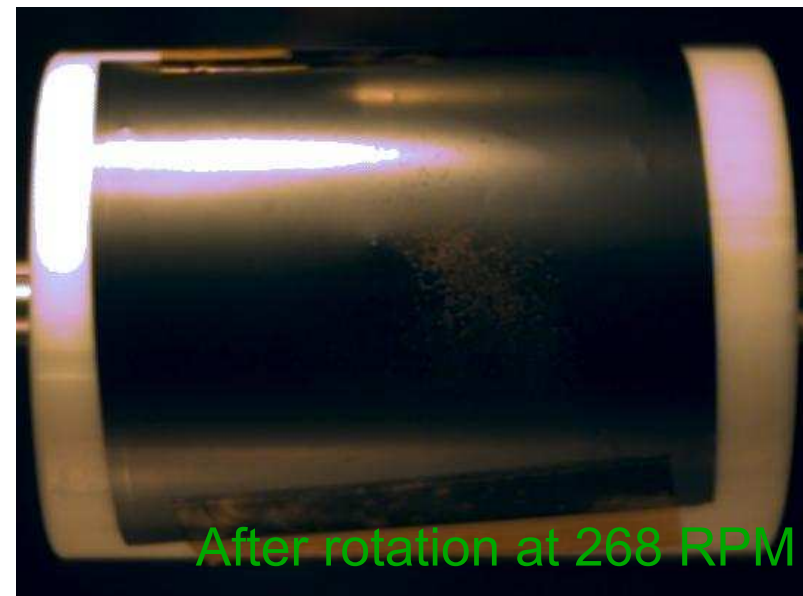
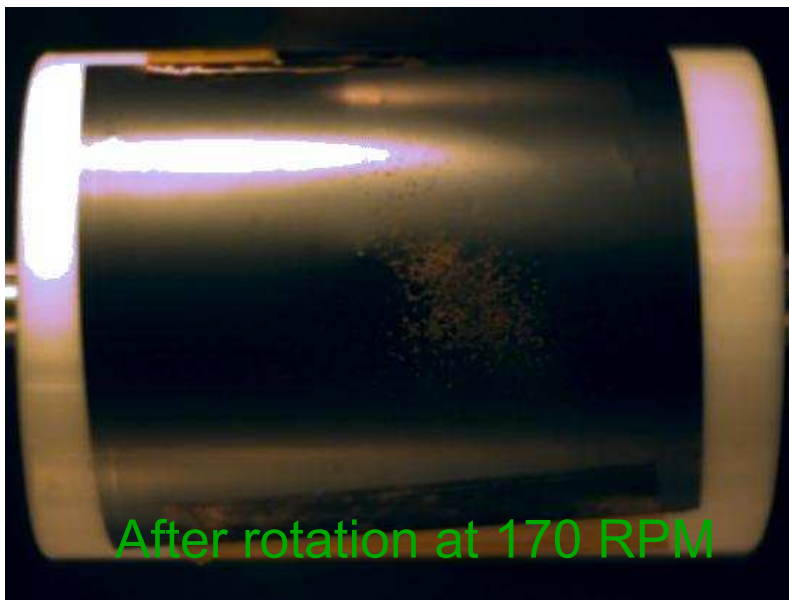
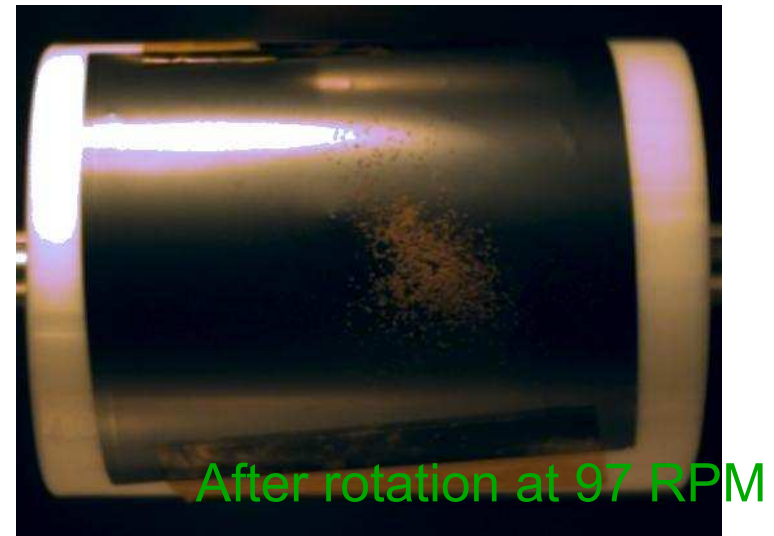
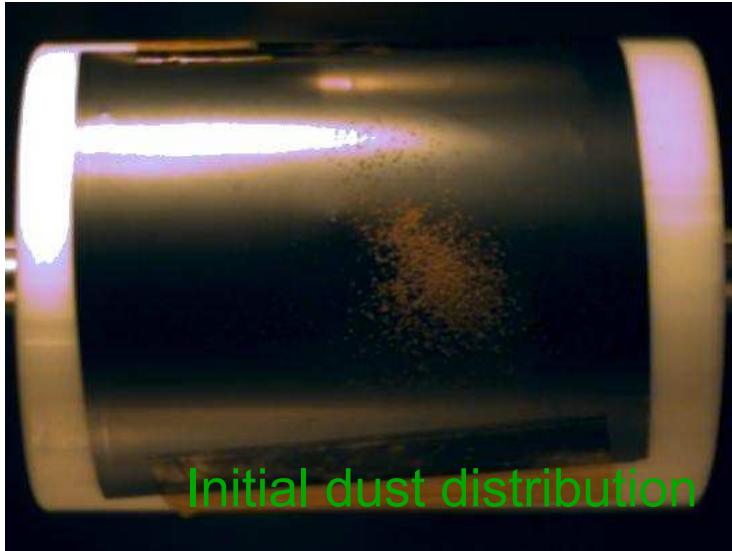
- Dust adheres well to virgin substrates (black Kapton, silicon, polycarbonate, quartz) and **coated (a:C:F)** silicon, polycarbonate, quartz.
- Dust does NOT adhere to coated black Kapton.
- Dust does NOT adhere to BATC proprietary treated black Kapton, silicon, polycarbonate or quartz.
- Consistent results have been observed numerous times.

- **Centrifugal force detachment:** Measures total adhesion
- Atomic Force Microscopy
- Electric field detachment





Coated Black Kapton (multiply by 3 for speeds) < 25 micron particles JSC-1





First results for black Kapton



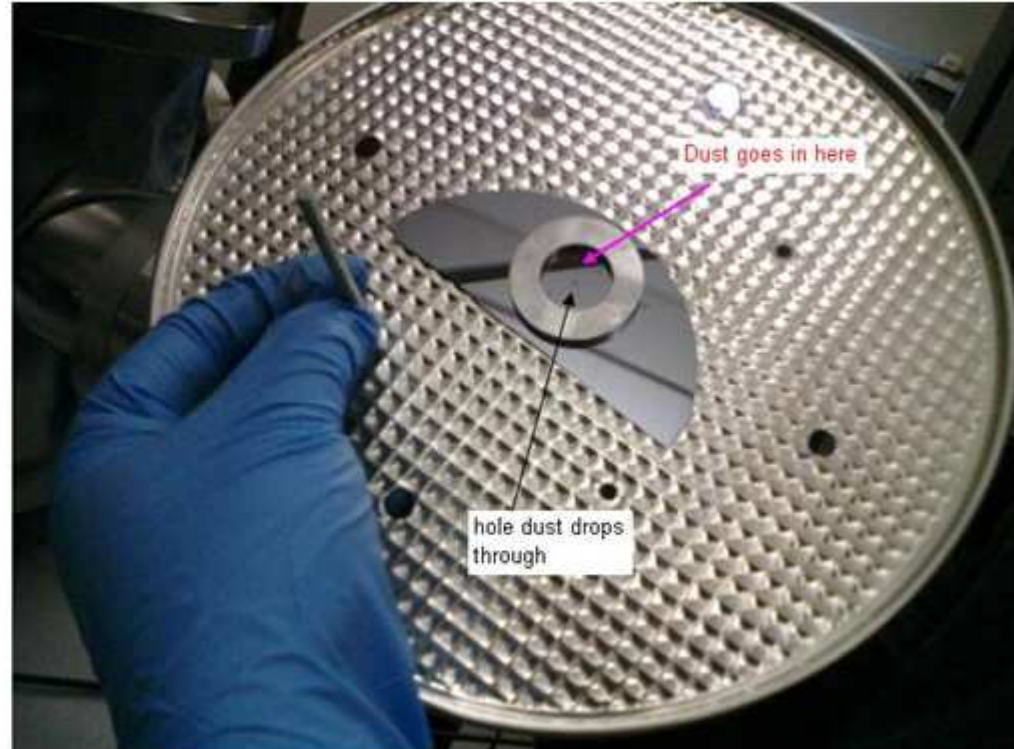
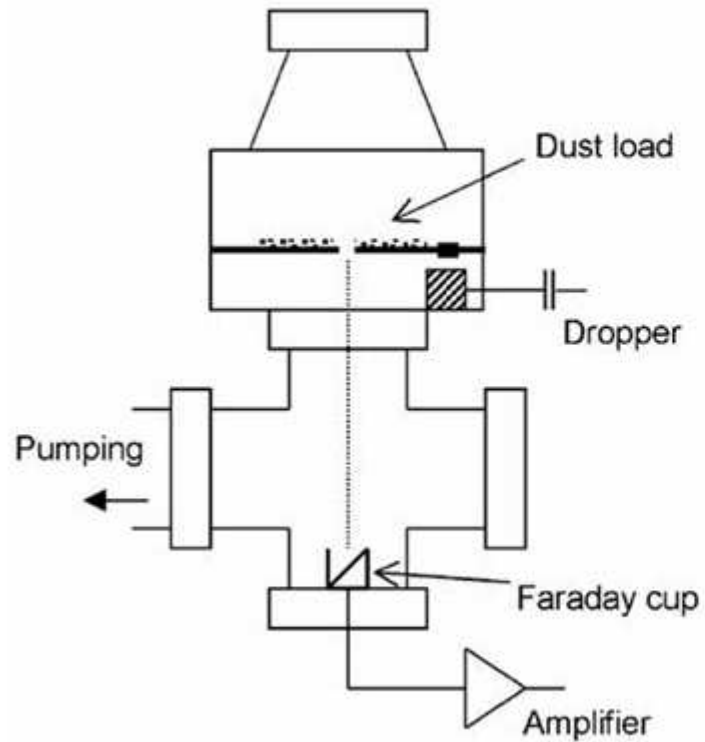
From the roller/centrifugal force experiments:

All done under vacuum, on the order of $1-3 \times 10^{-6}$ torr

First "major" removal of dust:

--> Coated has lower adhesion than untreated

--> Treated has lower adhesion than untreated (perhaps even lower than coated)

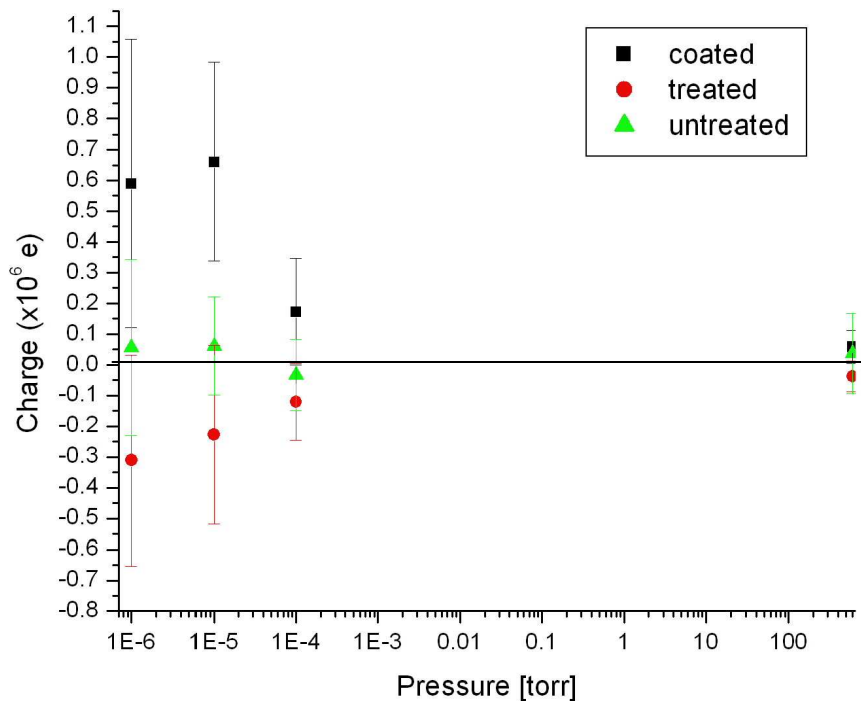




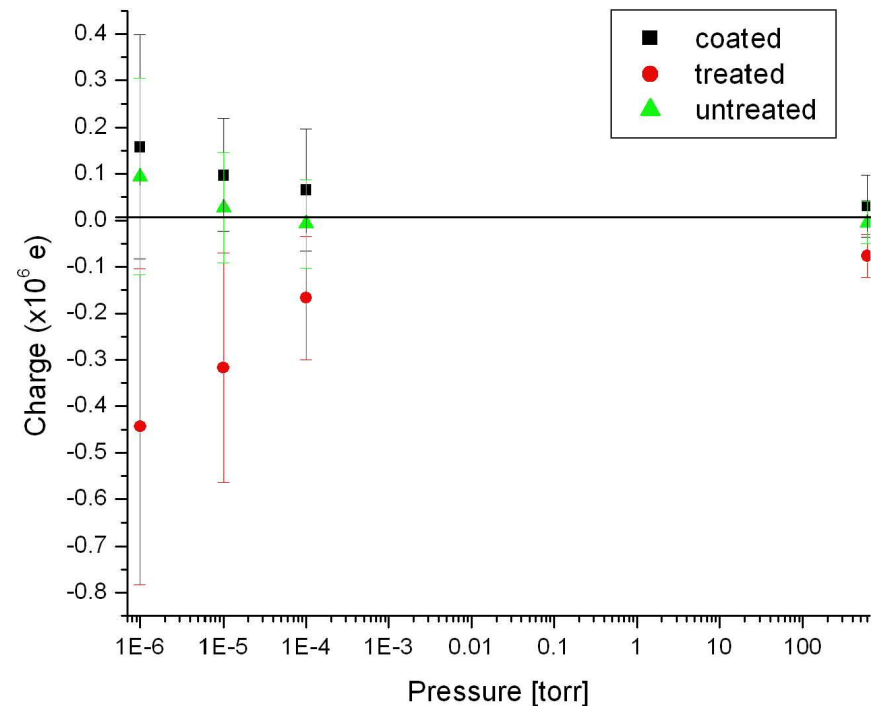
Contact Charging Data



Black Kapton w/ 180-212 μ m JSC-Mars-1

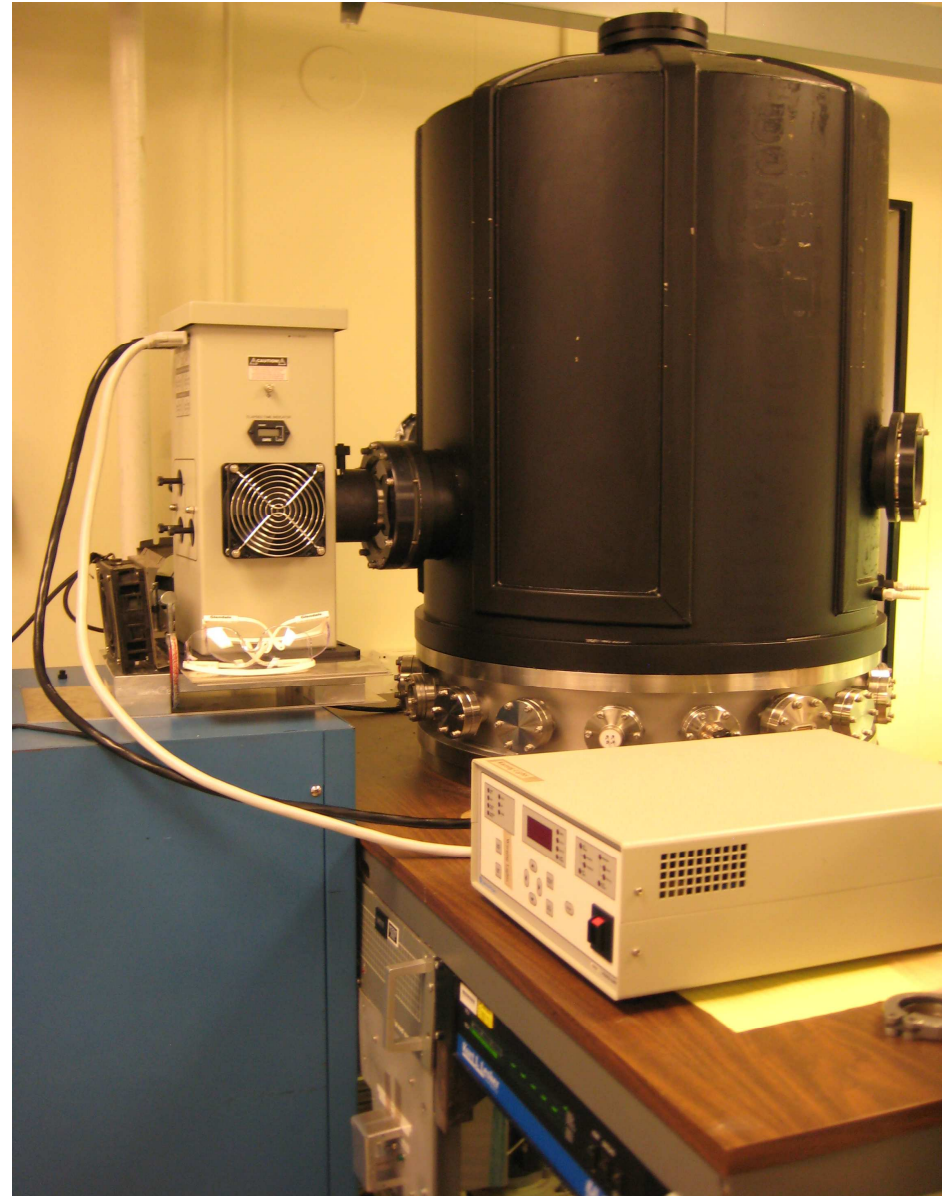


Si substrate w/ 180-212 μ m JSC-Mars-1



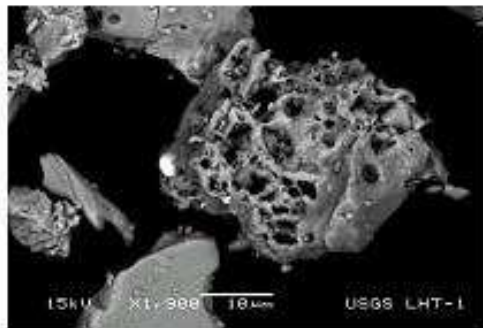
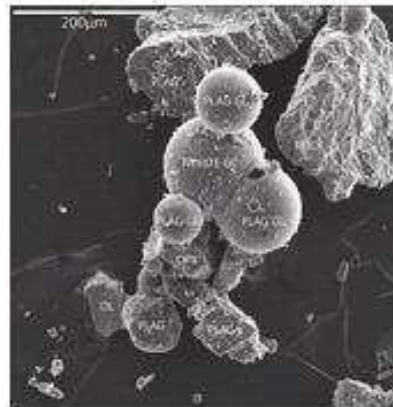
- The magnitude of the charge transfer is substantially greater with increased vacuum, as compared with air.
- Particles which move across the coated film (amorphous C:F) donate electrons.
- Particles which move across virgin surfaces pick up very little charge; the charge transfer is the lowest of all types of surfaces.
- Particles which move across treated surfaces pick up small negative electric charge.

- **Simulate extraterrestrial UV environment**
- **UV Sources:**
 - Hg(Ar)
 - Xenon
- **Irradiance - function of:**
 - Distance from source
 - Exposure Time
- **Study:**
 - How UV exposure impacts particle adhesion



Xenon lamp into chamber window

Refinement of process parameters for producing surfaces which shed dust, including other types of materials: metals, space suit material, etc.



Effect of size,
type,
morphology,
plasma, UV,
environment....

Lunar Simulants: Top left is JSC-1AF, the other images are those of various ZAP lunar simulants.